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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the Application of

Mark Robert SIVIK et al.

Group Art Unit: 1751

Serial No.: 09/699,522

Examiner : J.R. Hardee

Filed: October 30, 2000

For: COMPOSITIONS AND METHODS FOR USING POLYMERIC SUDS ENHANCERS

**INFORMATION DISCLOSURE STATEMENT**

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

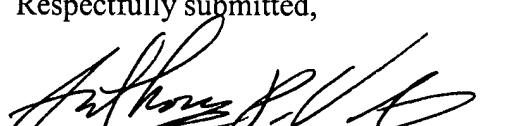
Pursuant to Rules 56 and 98, Applicants hereby call the attention of the Patent Office to the references listed on the attached Form PTO 1449.

Applicants present these references so that the Patent Office may, in the first instance, determine any relevancy thereof to the presently claimed invention, see Beckman Instruments, Inc. v. Chemtronics, Inc., 439 F.2d 1369, 1380, 165 USPQ 355, 364 (5th Cir. 1970). Applicants respectfully request that these references be expressly considered during the prosecution of this application and made of record herein and appear among the "References Cited" on any patent to issue herefrom.

Respectfully submitted,

Date: March 17, 2004

By:



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SHEET 1 OF 1

FORM PTO-1449 U.S. Department of Commerce  
(Rev. 4/92) Patent and Trademark Office

## INFORMATION DISCLOSURE STATEMENT BY APPLICANT

(Use several sheets if necessary)

ATTY. DOCKET NO.  
APV30270CIP

ATTY. DOCKET NO.  
APV31122

APPLICANT  
Sivik et al.

FILING DATE  
October 30, 2000

## GROUP

## U.S. PATENT DOCUMENTS

## FOREIGN PATENT DOCUMENTS

**OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, Etc.)**

US Patent Application Publication No. US 2003/0144167 A1, filed Jan. 4, 2002, published July 31, 2003, SIVIK et al.

**EXAMINER**

**DATE CONSIDERED**

**EXAMINER:** Initial if citation is considered, draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.